

SCOPE

In the past three decades, surface analysis has advanced considerably and is now applied extensively in industries that use cutting-edge technology. The scope of this series of international symposia on surface chemical analysis covers the present status and future prospects of surface-analytical techniques in various practical applications. Special emphasis has been given to applications involving techniques such as Auger Electron Spectroscopy, X-ray Photoelectron Spectroscopy, Electron Microprobe Analysis, Secondary Ion Mass Spectrometry, Scanning Probe Microscopy, etc. Important subjects for standardization will be discussed with examples from applications in different industries, reliability of the techniques, development of expert systems, numerical simulations, theoretical calculations, data processing, and support systems for analyses. Fundamental research contributing to improvements in surface-analytical techniques are also within the scope of this symposium. The 6th Korea-Japan International Symposium on Surface Analysis will be held in conjunction with the PSA-07 symposium. All scientists interested in the PSA topics are invited to attend the Symposium in the historic city of Kanazawa, Japan. Domestic VAMAS/TWA2 activity workshop on surface analysis is planned for November 29 to December 1 following the PSA conference.

CONTRIBUTION to PSA-07

Some contributed papers will be presented orally, and others in poster sessions. Papers, accepted after peer review by appropriate referees, will be published in a special issue of the Journal of Surface Analysis following the symposium. Further details will be announced in the second announcement on the web site.

INVITED SPEAKERS

Many excellent invited talks are scheduled to make the PSA-07 International Symposium more effective in the exchange of information, taking into account the importance of both the practical and fundamental researches in surface analysis.

LANGUAGE

The official language of the symposium is **English**.

REGISTRATION FEE

The registration fee is **JPY 35,000** for the pre-registration (before **August 31, 2007**). It will be **JPY 45,000** for the registration after **September 1, 2007**.

DATE and VENUE

The international symposium will be held at **Ishikawa Ongakudo** in Kanazawa, Ishikawa, Japan from November 25, Sunday to 28, Wednesday, 2007.

DEADLINES & KEY DATES

Abstract submission deadline: **July 31, 2007**

Registration must be done before:

August 31, 2007

Manuscript deadline for proceedings:

November 26, 2007

ACCOMMODATION

Kanazawa Miyako Hotel is recommended. Further information will be announced in the 2nd announcement on the web site.

ABSTRACT

One page abstract (A4) **without figure** should be sent to the secretariat of the symposium. Further information will be available at the web site: <http://www.sasj.jp/PSA/PSA07/>

SYMPOSIUM SECRETARY

All inquiries should be addressed to:

Dr. Daisuke Fujita

PSA-07 Symposium Secretary
National Institute for Materials Science
1-2-1 Sengen, Tsukuba 305-0047, JAPAN
E-mail: FUJITA.Daisuke@nims.go.jp
TEL: +81-29-859-2741 FAX: +81-29-859-2501

**For up-to-date information,
please visit our Web site:**

<http://www.sasj.jp/PSA/PSA07/>